

	Type	L #	Hits	Search Text	DBs	Time Stamp
1	BRS	L1	140	(water near soluble near polymer) same ((silicon or metal) near polymer)	USPAT; US-PGPU B; EPO; JPO; DERWEN T; IBM_TDB	2004/01/25 11:06
2	BRS	L2	0	1 same (polysilsequioxane or spin near on near silicon or "SOG")	USPAT; US-PGPU B; EPO; JPO; DERWEN T; IBM_TDB	2004/01/25 11:08
3	BRS	L3	9	polysilsequioxane same ((spin near on near silicon) or "SOG")	USPAT; US-PGPU B; EPO; JPO; DERWEN T; IBM_TDB	2004/01/25 11:08
4	BRS	L4	0	1 same (polysilsequioxane or spin near on near glass or "SOG")	USPAT; US-PGPU B; EPO; JPO; DERWEN T; IBM_TDB	2004/01/25 11:08
5	BRS	L5	0	1 same (polysilsequioxane or (spin near on near glass) or "SOG")	USPAT; US-PGPU B; EPO; JPO; DERWEN T; IBM_TDB	2004/01/25 11:09
6	BRS	L6	257	(water near soluble or dissolv\$3) same (polysilsequioxane or (spin near on near glass) or "SOG")	USPAT; US-PGPU B; EPO; JPO; DERWEN T; IBM_TDB	2004/01/25 11:10
7	BRS	L8	0	7 and @pd<20000927	USPAT; US-PGPU B; EPO; JPO; DERWEN T; IBM_TDB	2004/01/25 11:12
8	BRS	L7	81	6 and (resist near pattern\$3)	USPAT; US-PGPU B; EPO; JPO; DERWEN T; IBM_TDB	2004/01/25 11:12

	Type	L #	Hits	Search Text	DBs	Time Stamp
9	BRS	L9	0	7 and @pd<20000927	USPAT; US-PGPU B; EPO; JPO; DERWEN T; IBM_TDB	2004/01/25 11:12
10	BRS	L20	84736	(water near (solubl\$5 or dissolv\$3)) same polymer	USPAT; US-PGPU B; EPO; JPO; DERWEN T; IBM_TDB	2004/01/25 11:59
11	BRS	L21	14384	20 same (silicon or metal or titanium or aluminum)	USPAT; US-PGPU B; EPO; JPO; DERWEN T; IBM_TDB	2004/01/25 12:00
12	BRS	L22	11	21 same (resist near pattern\$3)	USPAT; US-PGPU B; EPO; JPO; DERWEN T; IBM_TDB	2004/01/25 12:03
13	BRS	L23	2	22 and @pd<20000927	USPAT; US-PGPU B; EPO; JPO; DERWEN T; IBM_TDB	2004/01/25 12:02
14	BRS	L24	0	21 same (polysilsequioxane or "SOG")	USPAT; US-PGPU B; EPO; JPO; DERWEN T; IBM_TDB	2004/01/25 12:04